

HCTS109MS

Radiation Hardened Dual JK Flip Flop

September 1995

Features

- 3 Micron Radiation Hardened SOS CMOS
- Total Dose 200K RAD (Si)
- SEP Effective LET No Upsets: >100 MEV-cm²/mg
- Single Event Upset (SEU) Immunity < 2 x 10⁻⁹ Errors/ Bit-Day (Typ)
- Dose Rate Survivability: >1 x 10¹² RAD (Si)/s
- Dose Rate Upset >10¹⁰ RAD (Si)/s 20ns Pulse
- Latch-Up Free Under Any Conditions
- Military Temperature Range: -55°C to +125°C
- Significant Power Reduction Compared to LSTTL ICs
- DC Operating Voltage Range: 4.5V to 5.5V
- . LSTTL Input Logic Compatibility
 - VIL = 0.8V Max
 - VIH = VCC/2 Min
- Input Current Levels Ii $\leq 5\mu A$ at VOL, VOH

Description

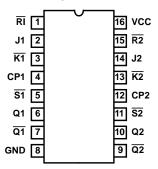
The Intersil HCTS109MS is a Radiation Hardened Dual JK Flip Flop with set and reset. The flip flop changes state with the positive transition of the clock (CP1 or CP2).

The HCTS109MS utilizes advanced CMOS/SOS technology to achieve high-speed operation. This device is a member of radiation hardened, high-speed, CMOS/SOS Logic Family.

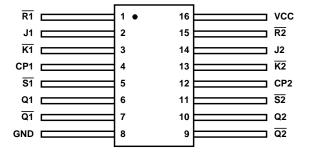
The HCTS109MS is supplied in a 16 lead Ceramic flatpack (K suffix) or a SBDIP Package (D suffix).

Pinouts

16 LEAD CERAMIC DUAL-IN-LINE METAL SEAL PACKAGE (SBDIP) MIL-STD-1835 CDIP2-T16, LEAD FINISH C TOP VIEW



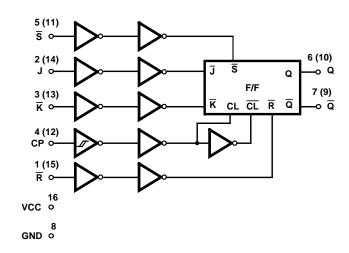
16 LEAD CERAMIC METAL SEAL FLATPACK PACKAGE (FLATPACK) MIL-STD-1835 CDFP4-F16, LEAD FINISH C TOP VIEW



Ordering Information

PART NUMBER	TEMPERATURE RANGE	SCREENING LEVEL	PACKAGE
HCTS109DMSR	-55°C to +125°C	Intersil Class S Equivalent	16 Lead SBDIP
HCTS109KMSR	-55°C to +125°C	Intersil Class S Equivalent	16 Lead Ceramic Flatpack
HCTS109D/Sample	+25°C	Sample	16 Lead SBDIP
HCTS109K/Sample	+25°C	Sample	16 Lead Ceramic Flatpack
HCTS109HMSR	+25°C	Die	Die

Functional Diagram



TRUTH TABLE

INPUTS					оиті	PUTS
s	R	СР	J	ĸ	Q	Q
L	Н	Х	Х	Х	Н	L
Н	L	Х	Х	Х	L	Н
L	L	Х	Х	Х	H*	H*
Н	Н		L	L	L	Н
Н	Н		Н	L	Тод	gle
Н	Н		L	Н	No Change	
Н	Н		Н	Н	H L	
Н	Н	L	Х	Х	No Change	

^{*}Unpredictable and unstable condition if both \overline{S} and \overline{R} go high simultaneously

Absolute Maximum Ratings

Supply Voltage (VCC)....-0.5V to +7.0V Input Voltage Range, All Inputs -0.5V to VCC +0.5V DC Input Current, Any One Input±10mA DC Drain Current, Any One Output.....±25mA

(All Voltage Reference to the VSS Terminal)

Storage Temperature Range (TSTG) -65 $^{\rm o}$ C to +150 $^{\rm o}$ C Lead Temperature (Soldering 10sec) +265°C Junction Temperature (TJ) +175°C

Reliability Information

Thermal Resistance SBDIP Package Ceramic Flatpack Package	θ _{JA} 73°C/W 114°C/W	θ _{JC} 24°C/W 29°C/W
Maximum Package Power Dissipation at +12		
SBDIP Package		
Ceramic Flatpack Package		
If device power exceeds package dissipation sinking or derate linearly at the following rate:		ovide heat
SBDIP Package		3.7mW/°C

CAUTION: As with all semiconductors, stress listed under "Absolute Maximum Ratings" may be applied to devices (one at a time) without resulting in permanent damage. This is a stress rating only. Exposure to absolute maximum rating conditions for extended periods may affect device reliability. The conditions listed under "Electrical Performance Characteristics" are the only conditions recommended for satisfactory device operation.

Operating Conditions

Supply Voltage (VCC)	. +4.5V to +5.5V
Operating Temperature Range (T _A)	-55°C to +125°C
Input Rise and Fall Times at VCC = 4.5V (TR. TF)	100ns/V Max.

TABLE 1. DC ELECTRICAL PERFORMANCE CHARACTERISTICS

	(NOTE 1) GROUP			LIMITS			
PARAMETER	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	20	μΑ
		VIIV = VGC OI GIVD	2, 3	+125°C, -55°C	-	400	μА
Output Current (Sink)	IOL	VCC = 4.5V, VIH = 4.5V, VOUT = 0.4V, VIL = 0V	1	+25°C	4.8	-	mA
(Ollik)		VOOT = 0.4V, VIL = 0V	2, 3	+125°C, -55°C	4.0	-	mA
Output Current (Source)	ЮН	VCC = 4.5V, VIH = 4.5V, VOUT = VCC -0.4V,	1	+25°C	-4.8	-	mA
(Source)		VIL = 0V	2, 3	+125°C, -55°C	-4.0	-	mA
Output Voltage Low VOL		VCC = 4.5V, VIH = 2.25V, IOL = 50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	V
		VCC = 5.5V, VIH = 2.75V, IOL = 50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	V
Output Voltage High VOH		VCC = 4.5V, VIH = 2.25V, IOH = -50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
		VCC = 5.5V, VIH = 2.75V, IOH = -50μA, VIL = 0.8V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
Input Leakage IIN Current		VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	±0.5	μΑ
		GNU	2, 3	+125°C, -55°C	-	±5.0	μΑ
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 2.25V, VIL = 0.8V (Note 2)	7, 8A, 8B	+25°C, +125°C, -55°C	-	-	-

NOTES:

- 1. All voltages reference to device GND.
- 2. For functional tests VO ≥ 4.0V is recognized as a logic "1", and VO ≤ 0.5V is recognized as a logic "0".

TABLE 2. AC ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTES 1, 2)	GROUP A		LIMITS		
PARAMETER	SYMBOL	CONDITIONS	SUBGROUPS	TEMPERATURE	MIN	MAX	UNITS
CP to Q, Q	TPLH	VCC = 4.5V	9	+25°C	2	26	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	30	ns
	TPHL	VCC = 4.5V	9	+25°C	2	30	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	35	ns
S̄ to Q	TPLH	VCC = 4.5V	9	+25°C	2	19	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	23	ns
S to Q	TPHL	VCC = 4.5V	9	+25°C	2	31	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	33	ns
R to Q	TPHL	VCC = 4.5V	9	+25°C	2	31	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	33	ns
R to Q	TPLH	VCC = 4.5V	9	+25°C	2	31	ns
		VCC = 4.5V	10, 11	+125°C, -55°C	2	33	ns

NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL = 500Ω , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = 3V.

TABLE 3. ELECTRICAL PERFORMANCE CHARACTERISTICS

					LIN	IITS	
PARAMETER	SYMBOL	CONDITIONS	NOTES	TEMPERATURE	MIN	MAX	UNITS
Capacitance Power	CPD	VCC = 5.0V, f = 1MHz	1	+25°C	-	80	pF
Dissipation			1	+125°C, -55°C	-	82	pF
Input Capacitance	CIN	VCC = 5.0V, f = 1MHz	1	+25°C	-	10	pF
			1	+125°C, -55°C	-	10	pF
Output Transition	TTHL	VCC = 4.5V	1	+25°C	-	15	ns
Time	TTLH		1	+125°C, -55°C	-	22	ns
Max Operating	FMAX	VCC = 4.5V	1	+25°C	-	27	MHz
Frequency			1	+125°C, -55°C	-	18	MHz
Setup Time J, K to	TSU	VCC = 4.5V	1	+25°C	16	-	ns
СР			1	+125°C, -55°C	18	-	ns
Hold Time J, K to CP	TH	VCC = 4.5V	1	+25°C	3	-	ns
			1	+125°C, -55°C	3	-	ns
Removal Time R,	TREM	VCC = 4.5V	1	+25°C	16	-	ns
S to CP			1	+125°C, -55°C	18	-	ns
Pulse Width R, S	$TW(\overline{S}, \overline{R})$	VCC = 4.5V	1	+25°C	16	-	ns
			1	+125°C, -55°C	18	-	ns
Pulse Width CP	TW (CP)	VCC = 4.5V	1	+25°C	24	-	ns
			1	+125°C, -55°C	27	-	ns

NOTE:

^{1.} The parameters listed in Table 3 are controlled via design or process parameters. Min and Max Limits are guaranteed but not directly tested. These parameters are characterized upon initial design release and upon design changes which affect these characteristics.

TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTES 4.2)		200K RAD LIMITS		
PARAMETER	SYMBOL	(NOTES 1, 2) CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	+25°C	-	0.4	mA
Output Current (Sink)	IOL	VCC = 4.5V, VIN = VCC or GND, VOUT = 0.4V	+25°C	4.0	-	mA
Output Current (Source)	IOH	VCC = 4.5V, VIN = VCC or GND, VOUT = VCC -0.4V	+25°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V and 5.5V, VIH = VCC/2, VIL = 0.8V, IOL = 50µA	+25°C	-	0.1	V
Output Voltage High	VOH	VCC = 4.5V and 5.5V, VIH = VCC/2, VIL = 0.8V, IOH = -50μA	+25°C	VCC -0.1	-	V
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	+25°C	-	±5	μА
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 2.25V, VIL = 0.8V, (Note 3)	+25°C	-	-	-
CP to Q, Q	TPLH	VCC = 4.5V	+25°C	2	30	ns
	TPHL	VCC = 4.5V	+25°C	2	35	ns
S to Q	TPLH	VCC = 4.5V	+25°C	2	23	ns
S to Q	TPHL	VCC = 4.5V	+25°C	2	33	ns
R to Q	TPHL	VCC = 4.5V	+25°C	2	33	ns
R to Q	TPLH	VCC = 4.5V	+25°C	2	33	ns

NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL = 500Ω , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = 3V.
- 3. For functional tests $VO \ge 4.0V$ is recognized as a logic "1", and $VO \le 0.5V$ is recognized as a logic "0".

TABLE 5. BURN-IN AND OPERATING LIFE TEST, DELTA PARAMETERS (+25°C)

PARAMETER	GROUP B SUB- GROUP	DELTA LIMIT
ICC	5	6µА
IOL/IOH	5	-15% of 0 Hour

TABLE 6. APPLICABLE SUBGROUPS

CONFORMANCE GROUPS		METHOD	GROUP A SUBGROUPS	READ AND RECORD
Initial Test (Preburn-I	n)	100%/5004	1, 7, 9	ICC, IOL/H
Interim Test I (Postbu	ırn-ln)	100%/5004	1, 7, 9	ICC, IOL/H
Interim Test II (Postb	urn-ln)	100%/5004	1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Interim Test III (Post	Interim Test III (Postburn-In)		1, 7, 9	ICC, IOL/H
PDA		100%/5004	1, 7, 9, Deltas	
Final Test		100%/5004	2, 3, 8A, 8B, 10, 11	
Group A (Note 1)		Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11	
Group B Subgroup B-5		Sample/5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11, Deltas	Subgroups 1, 2, 3, 9, 10, 11, (Note 2)
	Subgroup B-6	Sample/5005	1, 7, 9	
Group D	<u>-</u>	Sample/5005	1, 7, 9	

NOTES:

- 1. Alternate Group A testing in accordance with Method 5005 of MIL-STD-883 may be exercised.
- 2. Table 5 parameters on.y.

TABLE 7. TOTAL DOSE IRRADIATION

CONFORMANCE		TE	ST	READ AND RECORD	
GROUPS	METHOD	PRE RAD	POST RAD	PRE RAD	POST RAD
Group E Subgroup 2	5005	1, 7, 9	Table 4	1, 9	Table 4 (Note 1)

NOTE:

1. Except FN test which will be performed 100% Go/No-Go.

TABLE 8. STATIC BURN-IN AND DYNAMIC BURN-IN TEST CONNECTIONS

				OSCILLATOR				
OPEN	GROUND	1/2 VCC = 3V ± 0.5V	$\text{VCC} = 6\text{V} \pm 0.5\text{V}$	50kHz	25kHz			
STATIC BURN	STATIC BURN-IN I TEST CONNECTIONS (Note 1)							
6, 7, 9, 10	1 - 5, 8, 11 - 15	-	16	-	-			
STATIC BURN	-IN II TEST CONNECTION	S (Note 1)						
6, 7, 9, 10	8	-	1 - 5, 11 - 16	-	-			
DYNAMIC BURN-IN TEST CONNECTIONS (Note 2)								
-	8	6, 7, 9, 10	1, 5, 11, 15, 16	4, 12	2, 3, 13, 14			

NOTES:

- 1. Each pin except VCC and GND will have a resistor of 10K $\!\Omega\pm5\%$ for static burn-in.
- 2. Each pin except VCC and GND will have a resistor of 1K $\!\Omega\pm5\%$ for dynamic burn-in.

TABLE 9. RRADIATION TEST CONNECTIONS

	OPEN	GROUND	$VCC = 5V \pm 0.5V$
1	6, 7, 9, 10	8	1, 2, 3, 4, 5, 11, 12, 13, 14, 15, 16

NOTE: Each pin except VCC and GND will have a resistor of 47K Ω \pm 5% for irradiation testing. Group E, Subgroup 2, sample size is 4 dice/wafer 0 failures.

HCTS109MS

Intersil Space Level Product Flow - 'MS'

Wafer Lot Acceptance (All Lots) Method 5007 (Includes SEM)

GAMMA Radiation Verification (Each Wafer) Method 1019, 4 Samples/Wafer, 0 Rejects

100% Nondestructive Bond Pull, Method 2023

Sample - Wire Bond Pull Monitor, Method 2011

Sample - Die Shear Monitor, Method 2019 or 2027

100% Internal Visual Inspection, Method 2010, Condition A

100% Temperature Cycle, Method 1010, Condition C, 10 Cycles

100% Constant Acceleration, Method 2001, Condition per Method 5004

100% PIND, Method 2020, Condition A

100% External Visual

100% Serialization

100% Initial Electrical Test (T0)

100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015

100% Interim Electrical Test 1 (T1)

100% Delta Calculation (T0-T1)

100% Static Burn-In 2, Condition A or B, 24 hrs. min., $+125^{\circ}$ C min., Method 1015

100% Interim Electrical Test 2 (T2)

100% Delta Calculation (T0-T2)

100% PDA 1, Method 5004 (Notes 1and 2)

100% Dynamic Burn-In, Condition D, 240 hrs., +125°C or Equivalent, Method 1015

100% Interim Electrical Test 3 (T3)

100% Delta Calculation (T0-T3)

100% PDA 2, Method 5004 (Note 2)

100% Final Electrical Test

100% Fine/Gross Leak, Method 1014

100% Radiographic, Method 2012 (Note 3)

100% External Visual, Method 2009

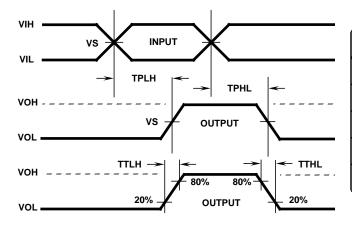
Sample - Group A, Method 5005 (Note 4)

100% Data Package Generation (Note 5)

NOTES:

- 1. Failures from Interim electrical test 1 and 2 are combined for determining PDA 1.
- 2. Failures from subgroup 1, 7, 9 and deltas are used for calculating PDA. The maximum allowable PDA = 5% with no more than 3% of the failures from subgroup 7.
- 3. Radiographic (X-Ray) inspection may be performed at any point after serialization as allowed by Method 5004.
- 4. Alternate Group A testing may be performed as allowed by MIL-STD-883, Method 5005.
- 5. Data Package Contents:
 - Cover Sheet (Intersil Name and/or Logo, P.O. Number, Customer Part Number, Lot Date Code, Intersil Part Number, Lot Number, Quantity).
 - Wafer Lot Acceptance Report (Method 5007). Includes reproductions of SEM photos with percent of step coverage.
 - GAMMA Radiation Report. Contains Cover page, disposition, Rad Dose, Lot Number, Test Package used, Specification Numbers, Test equipment, etc. Radiation Read and Record data on file at Intersil.
 - X-Ray report and film. Includes penetrometer measurements.
 - Screening, Electrical, and Group A attributes (Screening attributes begin after package seal).
 - Lot Serial Number Sheet (Good units serial number and lot number).
 - Variables Data (All Delta operations). Data is identified by serial number. Data header includes lot number and date of test.
 - The Certificate of Conformance is a part of the shipping invoice and is not part of the Data Book. The Certificate of Conformance is signed by an authorized Quality Representative.

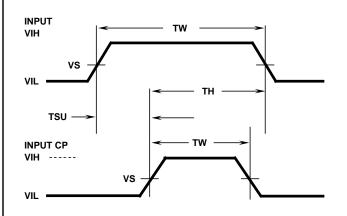
AC Timing Diagrams



AC VOLTAGE LEVELS

PARAMETER	нстѕ	UNITS
VCC	4.50	V
VIH	3.00	V
VS	1.30	V
VIL	0	V
GND	0	V

Pulse Width, Setup, Hold Timing Diagram Positive Edge Trigger



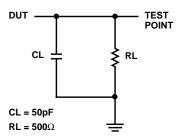
VOLTAGE LEVELS

PARAMETER	нстѕ	UNITS
VCC	4.50	V
VIH	3.00	V
VS	1.30	V
VIL	0	V
GND	0	V

TH = HOLD TIME TSU = SETUP TIME

TW = PULSE WIDTH

AC Load Circuit



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Die Characteristics

DIE DIMENSIONS:

89 x 88 mils 2.25 X 2.24mm

METALLIZATION:

Type: AlSi

Metal Thickness: 11kÅ ± 1kÅ

GLASSIVATION:

Type: SiO₂

Thickness: 13kÅ ± 2.6kÅ

WORST CASE CURRENT DENSITY:

 $<2.0 \times 10^5 \text{A/cm}^2$

BOND PAD SIZE:

 $100\mu m\ x\ 100\mu m$ 4 mils x 4 mils

Metallization Mask Layout

$\overline{R1}$ VCC J1 (2) (1) (16) (15) R2 K1 (3) (14) J2 CP1 (4) S1 (5) (13) K2 Q1 (6) (12) CP2 (11) S2 Q1 (7)

HCTS109MS

NOTE: The die diagram is a generic plot form a similar HCS device. It is intended to indicate approximate die size and bond pad location. The mask series for the HCTS109 is TA14440A.

(9) Q2 (10)

Q2

(8)

GND